L Number	Hits	Search Text	DB	Time stamp
1	852	kobayashi-shinji$.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:51
2	170	kitano-takahiro$.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:51
3	147	sugimoto-shinichi$.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:52
4	6717	(semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:53
5	1068824	vacuum or (reduced adj pressure) or (negative adj pressure)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:54
6	1151060	vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 13:59
7	2984	(vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$) and ((semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:13
8	439	((vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$) and ((semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$))) and (solvent near3 reduc$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:16
9	1	(((vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$) and ((semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$))) and (solvent near3 reduc$)) and (straighten$ near3 vane)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:02
10	23032	(clamp or clamping) near3 (semiconductor or wafer or substrate or disk or disc)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:03
11	4	(((vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$) and ((semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$))) and (solvent near3 reduc$)) and ((clamp or clamping) near3 (semiconductor or wafer or substrate or disk or disc))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:05
12	7	("4633804" | "5059266" | "5578127" | "5662785" | "5804046" | "6033480" | "6063190").PN.	USPAT	2004/09/02 14:04
13	67	(((vacuum or (reduced adj pressure) or (negative adj pressure) or evacuat$) and ((semiconductor or wafer or substrate or disk or disc) near13 (solvent near3 evaporat$))) and (solvent near3 reduc$)) and (aligner or alignment or aligning)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:18

14	208080	control?$4 near3 (pressure or vacuum$ or evacuat?$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:14
15	1390	(control?$4 near3 (pressure or vacuum$ or evacuat?$3)) and (solvent near3 reduc$)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:17
16	4411	(control?$4 near3 (pressure or vacuum$ or evacuat?$3)) and (solvent near3 remov?$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:17
18	648	((control?$4 near3 (pressure or vacuum$ or evacuat?$3)) and (solvent near3 remov?$3)) and (aligner or alignment or aligning)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:18
17	116	((control?$4 near3 (pressure or vacuum$ or evacuat?$3)) and (solvent near3 reduc$)) and (aligner or alignment or aligning)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/09/02 14:18